N THE UNITED STATES PATENT AND TRADEMARK OFFICE

application of: Zhu et al.

Attorney Docket No.:

NOVLP090/NVLS-002888

Application No.: 10/733,858

Examiner: Smith, Bradley

Filed: December 10, 2003

Group: 2891

Title: BIASED H₂ ETCH PROCESS IN

DEPOSTION-ETCH-DEPOSITION

GAP FILL

Confirmation No. 7860

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on June 20, 2006 in an envelope addressed to the Commissioner for Patents, P.O. Box 1450

Alexandria, VA 223/3-1450.

Tara Hayden

AMENDMENT TRANSMITTAL

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

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Transmitted herewith is an Amendment in the above-identified application.

The fee has been calculated as shown below.

	Claims After Amendment		Highest Previously Paid For	Present Extra	Small Entity Rate Fee	Large Entity Rate Fee
Total Claims	20	MINUS	20	00	x 25 =	x 50 = 00
Independent Claims	02	MINUS	03	00	x 100 =	x 200 = 00
Multiple Depe	ndent Claim Pro	esent and Fe	e Not Previous	ly Paid		
				Total	\$	\$00

Applicant(s) hereby petition for a _____ month extension(s) of time to respond to the

aforementioned Office Action.

Applicant(s) believe that no (additional) Extension of Time is required; however, if it is determined that such an extension is required, Applicant(s) hereby petition that such an extension be granted and authorize the Commissioner to charge the required fees for an Extension of Time under 37 CFR 1.136 to Deposit Account No. 500388.

Enclosed is our Check No. ____ in the amount of \$____ to cover the additional

claim fee and/or extension of time fees.

Please charge the required fees and any additional fees required to facilitate filing the enclosed response, to Deposit Account No. 500388 (Order No. NOVLP090).

Respectfully submitted,

YER WEAVER & THOMAS, LLP

Reg. No. 39,489

P.O. Box 70250 Oakland, CA 94612-0250



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Alexandria, VA 223

Signed:

Tara Hayden

RESPONSE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

This is in response to the Office Action mailed March 24, 2006. Please consider the following remarks prior to taking further action on this application:

Amendments to the Claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.